

FORM 1449* INFORMATION DISCLOSURE STATEMENT IN AN APPLICATION (Use several sheets if necessary)			Docket Number: 12052.17USD2	Application Number: Unknown
			Applicant: KOYAMA, et al.	
			Filing Date: Herewith	Group Art Unit: Unknown

U.S. PATENT DOCUMENTS						
EXAMINER INITIAL	DOCUMENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
jj	5,691,792	November, 1997	Mizushima, et al.			
jj	5,607,732	March, 1997	Miyamoto, et al.			
FOREIGN PATENT DOCUMENTS						
	DOCUMENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION
						YES
jj	JP 8-508207	09/03/96	Japan			Abstract
jj	JP 8-057678	03/05/96	Japan			Abstract
jj	JP 8-025045	03/13/96	Japan			Abstract
jj	JP 8-009794	01/31/96	Japan			Abstract
jj	JP 7-168023	07/04/95	Japan			Abstract
jj	JP 7-102470	11/08/95	Japan			Abstract
jj	JP 7-051400	06/15/95	Japan			Abstract
jj	JP 7-4675	01/25/95	Japan			Abstract
jj	JP 5-303916	11/16/93	Japan			Abstract
jj	JP 5-200577	08/10/93	Japan			Abstract
jj	JP 4-253583	09/09/92	Japan			Abstract
jj	JP 50-42499	04/17/75	Japan			Abstract
jj	DE 43 38 969	09/19/96	Germany			Abstract
jj	EP 629 592	02/12/94	EPO			Abstract
jj	WP 94/04744	03/03/94	PCT			
jj	EP 0682 272	11/15/95	EPO			
jj	DE 195 44 295	6/5/97	Germany			
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)						
jj	1993	Yablonovitch, E., "Photonic band-gap structures" <i>J. Opt. Soc. Am.</i> , vol. 10, no. 2, February 1993				
jj	1996	Tyan, Rong-Chung, Pang-Chen Sun, Axel Scherer and Yeshayahu Fainman, "Polarizing beam splitter based on the anisotropic spectral reflectivity characteristic of form-birefringent multi-layer gratings", <i>Optics Letters</i> , Vol. 21, no. 10, May 15, 1996.				
jj	1981	Murahara, Masataka; Yoshiyuki Kawamura; Koichi Toyoda, and Susumu Namba, "Fabrication of PMMA Holographic Grating by KrF Excimer Laser", December 14, 1981				
jj	1996	Holmer, Anna-Karin, Simultaneous Machining of Parallel Grooves in SnO ₂ Thin Films Using a ND:YAG Laser and a Kinoform, May 20, 1996, pp. 2614-18, <i>Applied Optics</i> , Vol. 35, No. 15				



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EXAMINER	<i>jj</i>	DATE CONSIDERED	3/10/05
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